

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant	:	Fujikawa et al.
Appl. No.	:	10/840,192
Filed	:	May 6, 2004
For	:	PREPARATION METHOD FOR NANOMATERIAL, METAL OXIDE NANOMATERIAL FORMING COMPOSITION USED THEREIN, AND METAL OXIDE NANOSTRUCTURE
Examiner	:	Lee, Edmund H.
Group Art Unit	:	1732

**AMENDMENT AND RESPONSE TO RESTRICTION REQUIREMENT****Mail Stop Amendment**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Dear Sir:

In response to the Restriction Requirement mailed **September 21, 2007**, please consider the following amendments and remarks.

Amendments to the claims are reflected in the listing of claims which begin on page 2 of this paper.

Remarks/Response to restriction requirement begin on page 6 of this paper.